| Form PTO-1449 US Dept. of Commerce (REV. 8-83) PATENT & TRADEMARK OFFICE INFORMATION DISCLOSURE STATEMENT | | | ATTY DOCKET NO. 126623 | | | | APPLICATION NO. New U.S. National Stage of | | | |
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| U.S. PATENT DOCUMENTS | | | | | | | | | | |
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| Examiner: Initial if citation considered, whether or not citation is in conformance with M.P.E.P. 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant | | | | | | | | | | |

Date: January 19, 2006